

Testbeam and gas issues

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## **Preparations for Bonn testbeam**

- Testbox sandwiched between 2 x 3 Mimosa planes
- Mechanically very well coupled
- Testbox position relative to the telescope has 3 degrees of freedom
  - Horizontally by remote control
    - ~ 1 mm accuracy
  - Manual adjustment vertically
    - ~ 10 μm accuracy
  - Manual rotation around vertical axis by goniometer
    - +/- 14 deg
    - ~ 0.1 deg accuracy





## **Preparations for Bonn testbeam**

- Most mechanics finished
  - Mimosa rails and pedestal still to be done
- Expected to be completed beginning of September



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## **Status ELSA still unclear**

## Probably no testbeam for us this year

■ Alternative Desy TB24/1



DESY Test Beam Schedule 2019 - Version 8 02/08/2019



Ralf Diener, Norbert Meyners, Marcel Stanitzki - DESY Test Beam Coordinators

	Week		TB21		TB22		TB24/1		TB24		
				DATURA		DURANTA	PCMAG	Telescope in PCMAG		AZALEA	
2-Sep-19	36		CMS-Pixel-Phase2		Setup Time						
9-Sep-19	37		CMS-Pixel-Phase2	х	ATLAS-ITk-Strips	х			CEPC-STCF	х	
16-Sep-19	38		AFP-TOF	х	Mu3e	х			CEPC-STCF	х	-
23-Sep-19	39		CLIC PIXEL	х	ATLAS-ITk-Pixel	х	TPEX		тотем	х	
30-Sep-19	40		X-Ray-Crystal-Rad	х	ATLAS-ITk-Pixel	х	ТРЕХ				Ż
7-Oct-19	41										Q
14-Oct-19	42		BL4S	х	SHiP-SplitCAL				ATLAS-ITk-TJCMOS		
21-Oct-19	43		BL4S	х	SHiP-SciFi						
28-Oct-19	44		CMS-Pixel-Phase2	х	SHiP-SciFi				SHiP-Emulsion+Ship-SBT		B
4-Nov-19	45		CMS-Pixel-Phase2	х	ATLAS-HGTD	х			LHCb-ECAL	х	-
11-Nov-19	46		FCAL	х	ATLAS-HGTD	х			LHCb-ECAL	х	
18-Nov-19	47				Setup Time						
25-Nov-19	48		CMS Outer Tracker	х	ATLAS-ITk-Strips	х			ATLAS-ITk-Pixel	х	
2-Dec-19	49		CMS Outer Tracker	х	ATLAS-ITk-Strips	х			ATLAS-ITk-Pixel	х	
9-Dec-19	50		ELIOT		CMS-Pixel-Phase2	х			Mu3e	х	
16-Dec-19	51	Beam till 20/12 0800	ELIOT		CMS-Pixel-Phase2	х			CLIC PIXEL	х	
23-Dec-19	52		Shutdown								
30-Dec-19	1		Shutuowii								

## **Options**

## Integration in LCTPC setup

Includes magnetic field

## Requires NEW testbox

- Design
- **Fabrication**
- Testing (laser)
- 0.5 to 1 year needed to get this operational

## Alternative: run parasitically outside the LCTPC setup

- Using the testbeam setup prepared for ELSA
- Probably not much work
- We would need a Desy movable table to get it in place



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## Unexpected transport behavior using the T2K mixture

- Vdrift always lower than expected
  - Suspects on CF4 bottle





90 bar left



## Single electron efficiency with 55Fe source

- Source Fe-55-04
  - 5.6 keV gamma
- Expecting with Ar a peak of ~220 e- and a second peak at ~ 110 e- (escape peak)
- Test repeated with T2K made from the new CF4 bottle

- Cluster tracing by finding hits within -40 to 400 ns window from 1<sup>st</sup> hit
- Cluster rate 25 100 Hz depending on chip position
  - => Igrid ~ 10 pA/chip
  - => hardly voltage drop across the protection layer



~ 10V higher Vgrid
needed to get the same
number of hits per cluster



Hits per cluster under 55Fe irradiation

## Gas gain old vs new CF4

For the new CF4 we need 10 V higher Vgrid to get the same ToT i.e. the same gas gain



## **Secondary emission**

- For the new CF4 we win on the secondary emission
- $\bullet 40 50\%$  less at the same ToT
- Second states a state of the state of the
- At 40 % secondary emission we have
  - 79% efficiency for the old CF4 mixture
  - 87% efficiency for the new CF4 mixture

#### Secondary emission fraction vs mean ToT for T2K gas From 55Fe irradiation Data 23-30 - 4 - 2019

From 55Fe irradiation Data 21-8-2019 From 55Fe with new CF4



## Deduced from 18% iC4H10 measurements: Single electron efficiency vs mean ToT

The acceptable working range (up to 50% secondary emission hits) has been significantly increased for the new CF4





## Diagram Nikhef gas filling system



## Discussion

- Old CF4 bottle might be polluted with argon in the early days of the system (2010)
- CF4 bottle pressure 17 bar
- Filling pressure 21 bar
  - => in case of a leaking valve the bottle mixture may flow backwards into the CF4 bottle

### For the new bottle this is excluded

- Backflow valve installed since then
- CF4 bottle pressure >> filling pressure

## ■ We will not soon empty the CF4 bottle as long as it is only used for T2K mixture

Bottle content sufficient for ~ 1500 T2K fillings

# Reference



 $J(nA/cm^2)$ 

- During testbeam we may easily have **30 – 40 V potential drop** across protection layer
- we need an extended working range

## Comparison of 3 different gases for chip 0 at mean ToT = 640 - 730 ns



## Comparison of 3 different gases for chip 0 at mean ToT = 1000 - 1200 ns



## **Comparison of 3 different gases for chip 0 at mean ToT = 1525 – 1600 ns**

=> single electron efficiency 95 %

